Search Notes			

 Application No.	Applicant(s)	
09/892,023	TAKAGI ET AL.	
Examiner	Art Unit	
W. David Coleman	2823	

SEARCHED			
Class	Subclass	Date	Examiner
438	706 730	12/8/2004	WDC
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INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner
438	706	12/8/2004	WDC
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SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
,	DATE	EXMR
EAST 1.4.1; Appliants claim a dry etch recipe wherein chlorine is used as the starting composition and CHF3 is added later to		
etch the lower most layer.	12/8/2004	WDC
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